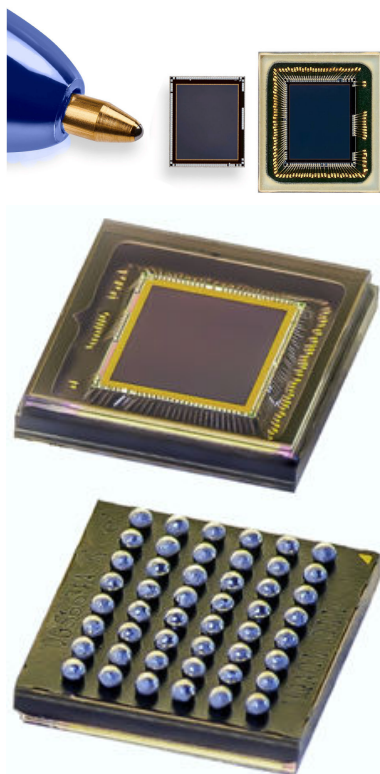# VB56G3, VD56G3

Compact and high-sensitivity 1.5 MP monochrome global shutter image sensors

Features

- **Resolution:** 1.53 MP (1124 x 1364)
- **Chroma:** Monochrome
- **Optical format:** 1/4'' (4.61 mm)
- **State-of-the-art pixel technology:**
  – Pixel pitch: 2.61 µm
  – Shutter type: Global shutter
  – Technologies: GS (global shutter), BSI (backside illumination), CDTI (continuous digital time integration), and 3D stacking (three-dimensional stacking).
- **Embedded features:**
  – Image quality optimization: Autoexposure, defective pixel correction, binning, and more.
  – Data and frame rate optimization: Cropping, subsampling, and more.
  – Others: Context management, temperature sensor, and more.
- **Interfaces:**
  – Output: MIPI CSI-2 (1 or 2 lanes) with RAW8 and RAW10 output formats
  – Control: I²C
- **Comprehensive evaluation hardware:**
  – VD56G3 promodules (CAM-56G3)
  – VD56G3 S-Board (STEVAL-56G3MAI)
  – EVK Main (STEVAL-EVK-U0I)
- **Compatible software tools:**
  – PC Evaluation software: STSW-IMG501
  – PC Software Development Kit (SDK): STSW-IMG507_56G3
  – Embedded platform drivers: STSW-IMG502

Order code	Description
VD56G3CCA/RW	Bare die as reconstructed wafer
VB56G3CAGK/1	OBGA sensor in tape and reel

Description

The VD56G3 and VB56G3 are 1.5-megapixel monochrome CMOS image sensors that deliver exceptional imaging performance in a compact form factor. Built on STMicroelectronics' proprietary technologies, including BSI and full CDTI, they achieve superior QE (quantum efficiency), MTF (modulation transfer function), and angular response for sharp, crystal-clear image capture, even in challenging conditions. With outstanding performance in both visible and near infrared light (850 nm, 940 nm), these sensors are ideal for precision-driven and versatile applications.

Their ultracompact footprint minimizes system size, featuring a small optical format of 4.6 mm (1/4") at full resolution, enabling the design of compact and ergonomic vision systems. With low-power consumption, they are ideal for battery-powered devices, while their robust design ensures reliable and consistent image quality across a wide range of temperatures.

Smart in-sensor features such as autoexposure, cropping, binning, and programmable sequences simplify development and optimize data throughput. Their MIPI CSI-2 interface (1 or 2 lanes) and I²C control ensures seamless connection to embedded processing platforms.

DS12968 - Rev 12 - October 2025
For further information, contact your local STMicroelectronics sales office.

www.st.com

The sensors offer unmatched flexibility. The VD56G3 is available as a sensor die for ultracompact camera modules, while the VB56G3 comes in an OBGA package for direct PCB integration. They are also part of a sensor family that includes color (RGB) versions VD66GY and VB66GY, and RGB-NIR versions VD16GZ and VB16GZ for even greater flexibility.

Supported by turnkey sensor boards, evaluation modules, and free drivers, the VD56G3 and VB56G3 accelerate development and empower engineers to build innovative, high-performance imaging solutions with ease and confidence.

Application

- Industrial, logistics, and smart retail
- Security, surveillance, and smart building
- Robotics and drones
- Home appliances
- AR/VR/XR
- Biometrics and authentication
- Medical

1   Acronyms and abbreviations

Table 1. Acronyms and abbreviations

Acronym/abbreviation	Definition
ADC	analog to digital converter
AE	autoexposure
AGV	automated guided vehicle
AR	augmented reality
BSI	backside illumination
CCI	camera control interface
CP	charge pump
CRA	chief ray angle
CSI	camera serial interface
DTI	deep trench isolation
EMC	electromagnetic compatibility
EMI	electromagnetic interference
FoV	field of view
fps	frames per second
GPIO	general-purpose input/output
I^2C	inter-integrated circuit (bus)
ISL	intelligent status line
ISP	image signal processor
LDO	low dropout regulator
LED	light-emitting diode
MCU	microcontroller unit
MIPI	mobile industry processor interface
MTF	modulation transfer function
NIR	near infrared
OIF	output interface
OTP	one-time programmable
PLL	phase-locked loop
PWM	pulse-width modulation
QE	quantum efficiency
RI	relative illumination
SW	software
UAV	unmanned aerial vehicle
UI	user interface for host to sensor communication
VR	virtual reality

2 Product overview

2.1 Functional description summary

The VD56G3, VB56G3 are 1.5-megapixel global shutter image sensors featuring a matrix of 1124 x 1364 pixels. With their global shutter operation, all pixels are synchronized to capture light at the same time. This removes the motion blur that can affect rolling shutter image sensors, when capturing changing or moving scenes.

Once the exposure is finished, each pixel information is transferred in a storage node, before being read and digitized one pixel row after the other. The image data are digitized using internal 10-bit ADCs. Additional gains can be applied before ADC stage (for example, analog gain) or after ADC stage (for example, digital gain). Following the digital conversion, various image preprocessing and correction algorithms can be applied into the sensors before data output, such as autoexposure or binning.

The image data are output as frames of RAW8 or RAW10 data through a MIPI CSI-2 interface. The sensors can be configured to operate with either 1 or 2 MIPI CSI-2 lanes to best fit with host processing requirements.

The VD56G3, VB56G3 are synchronized to the rest of the system by means of an external clock, triggers, and general-purpose input/output (GPIO) signals that can be used to enable synchronization of several sensor readouts or to control strobe light sources during exposure time.

The devices are fully configurable through the I²C serial interface and provides flexible frame-to-frame parameter configuration changes via the use of programmable contexts. It also embeds a one-time programmable (OTP) nonvolatile memory to be written by 32-bit words.

Figure 1. Functional block diagram
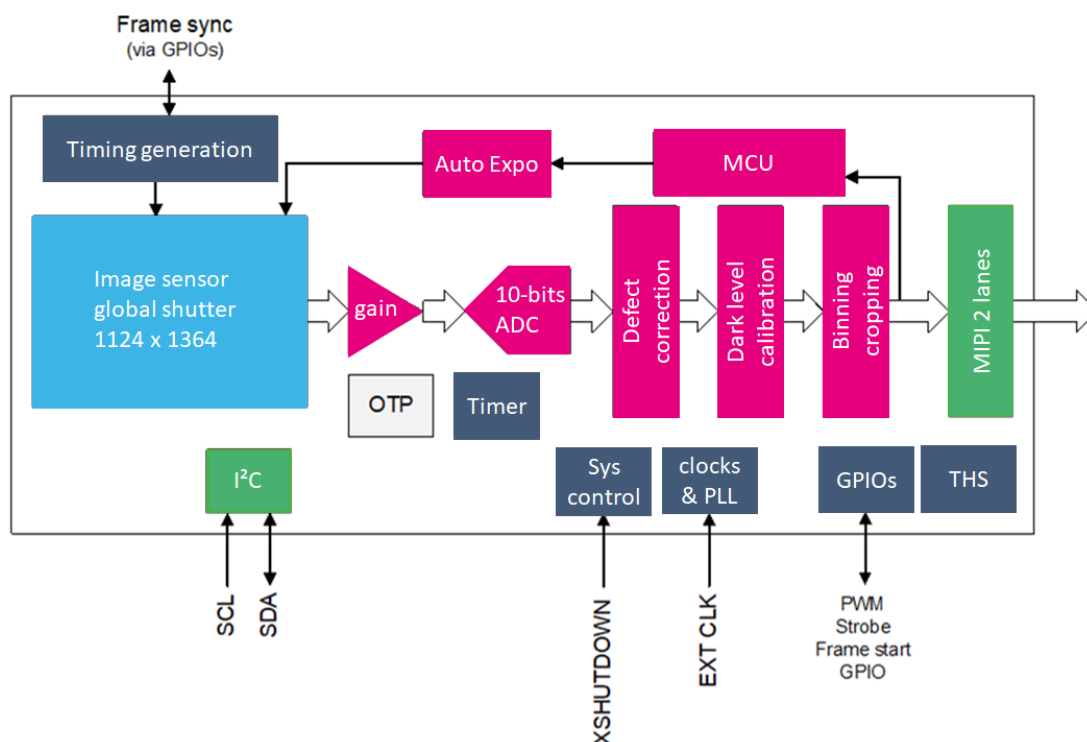
2.2 Technical specifications summary

Table 2. **Technical specifications**

Category	Parameter	Specifications
Resolution	Resolution	1.53 MP
	Pixel array [H x V]	1124 x 1364
	Aspect ratio	5:6
Pixel	Shutter type	Global shutter
	Illumination type	BSI
	Pixel size	2.61 µm
Color	Color option	Monochrome
Frame rates (maximum)	Full resolution	88 fps
	1 MP resolution	121 fps
	VGA resolution	237 fps
Optical characteristics	Pixel array size [H x V]	2.93 mm x 3.56 mm
	Optical format	1/4" (4.61 mm)
	CRA	26° linear
	QE at 940 nm	22%
Mechanical characteristics	Die footprint [H x V]	3.65 mm x 4.34 mm
	Die centering (optical vs. mechanical)	Yes
	Die pinout	115 pins
	Operating temperature range	-30 to +85°C
Electronic characteristics	Sensor data interface	MIPI CSI-2 | 1 or 2 lanes
	Sensor control interface	I²C, up to 1 Mbits/s
	Output format	RAW8, RAW10
	Supply voltages	2.8 V – 1.8 V – 1.15 V
	External clock frequency	6 to 27 MHz
	Power consumption	120 mW (typical) | 4 mW (standby)
Embedded features	Image quality optimization	• Autoexposure • Automatic dark calibration • Defective pixel correction • Analog and digital gains • Binning
	Data and frame rate optimization	• Cropping • Subsampling • Context management with up to 4 contexts
	Others	• Mirror/Flip • Test pattern generation • Temperature sensor

3 Functional description

3.1 Interfaces

3.1.1 Inter-integrated circuit (I²C)

The VD56G3, VB56G3 are configured and controlled via an I²C interface operating in either fast mode (up to 400 kHz) or fast mode plus (up to 1 MHz) at 1.8 V. After the MCU boot sequence, the default I²C configuration is fast mode plus with a sink capability set to 20 mA. Drive capability can be decreased to 4 mA (fast mode) by writing a dedicated register once the system has booted. Device addressing uses a CCI protocol with 2 byte subaddresses. The default address of the sensors is 0x20 (including R/W bit), and can be overridden:

• Permanently by storing a non-null value in a dedicated OTP register.
• Dynamically with a firmware command when the MCU state is SW_STANDBY.

3.1.2 Camera serial interface (CSI)

The sensors are ready to connect via a dual lane mobile industry processor interface (MIPI) CSI-2 serial interface.

The dual lane MIPI CSI-2 serial interface supports up to 1.5 Gbps per lane. It is the industry standard for low electromagnetic interference (EMI) and excellent electromagnetic compatibility (EMC) high-speed interfacing. The CSI lane number can be lowered to a single lane. Resolution is scalable between RAW8 and RAW10.

3.2 Power supplies

The power supplies required by the sensors are:

• 2.8 V for the analog blocks
• 1.8 V for the digital I/Os
• 1.15 V for the core digital logic and MIPI CSI-2 output drivers

The pixel array requires different positive and negative voltages, all internally generated by charge pumps and regulators. Four voltage references, internally generated, need external decoupling capacitors. The internal MCU handles the entire power management of the sensors to guarantee the lowest power consumption at any given time.

3.3 Clock and PLL

An input clock is required from an external digital clock source in the range of 6 to 27 MHz. Firmware is preconfigured for a 12 MHz external source clock. Two built-in PLL (phase-locked loop) blocks generate all necessary internal clocks for the pixel array, processing pipe, and output interface.

3.4 Video pipe

The video pipe performs several features designed to ensure a high quality image. These features include:

- Analog subsampling
- Pattern generation
- Dynamic defective pixel correction
- Dark calibration
- Autoexposure
- Digital binning
- Embedded status lines
- Output interface
- Context management
- Cropping

The diagram below presents the features implementation in the video pipe

Figure 2. Image signal processor schematic
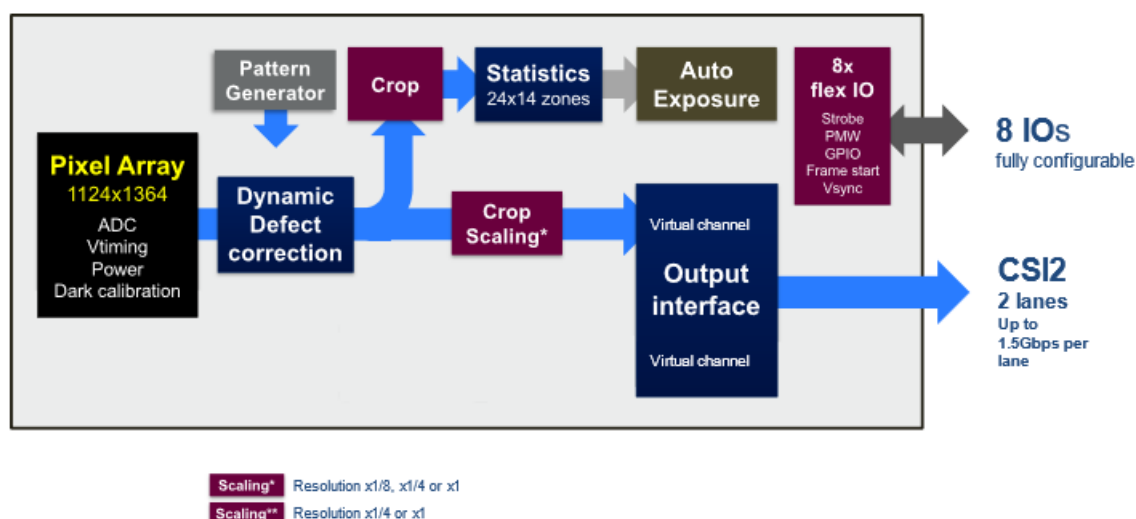
3.4.1 Pattern generation

The pattern generation allows the generation of digital patterns in the output frame for test and debug. It is also possible to insert a cross bar in the image with configurable position, size, and brightness. The available patterns are:

- Solid color
- Color bars
- Vertical gray scale
- Horizontal gray scale
- Diagonal gray scale
- Pseudorandom data

Figure 3. Available patterns

Solid color   Color bars   Vertical grayscale

Horizontal grayscale   Diagonal grayscale   Pseudo-random data
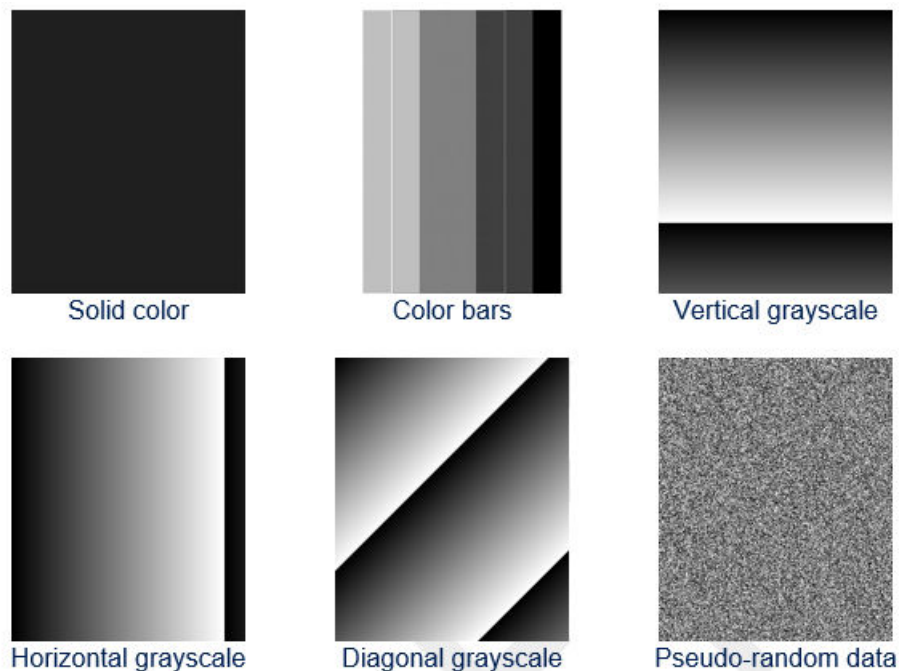
3.4.2 Defective pixel correction

Active pixels are automatically corrected by a dynamic algorithm embedded in the sensor's ISP. This enables defect-free images directly from the sensors without the need for additional algorithm development or processing resources.

The advanced correction algorithm can correct singlet and couplet of defects and take into account local spatial gradients.

The host can program the strength of the correction to find the perfect balance between systematic defect correction and preserving existing textures/patterns in the image. The correction strength evolves automatically with exposure time. This mechanism can be deactivated for debugging purposes and for specific use cases such as structured light.

3.4.3 Dark calibration

The pixel matrix has dedicated lines with shielded pixels that dynamically retrieve the dark level and subtract it from the active image. Temperature, exposure time, or gain changes are compensated. Temporal smoothing and fractional bit dithering are applied to avoid a sudden one-code step. This block also embeds a programmable digital gain control feature with a granularity of 1/256 followed by a configurable pedestal to offset the dark level along the ISP pipe.

3.4.4 Analog and digital gains

The VD56G3, VB56G3 enable adjustment of the analog and digital gains on the image to optimize image quality depending on the lighting conditions. Gains are adjusted automatically when autoexposure is enabled, or by manual control when autoexposure is disabled.

Analog gain ranges from x1 (+ 0 dB) up to x8 (+18 dB) with 29 steps following a 1/X behavior enabling to benefit from fine gain granularity at low gain and wider granularity at high gains to better adjust image quality. It follows the following formula:

$$Analog\ gain\left(x\right) = \frac{32}{32 - x}$$

Where x is an integer from 0 to 28.

Figure 4. Analog gain progression versus control code
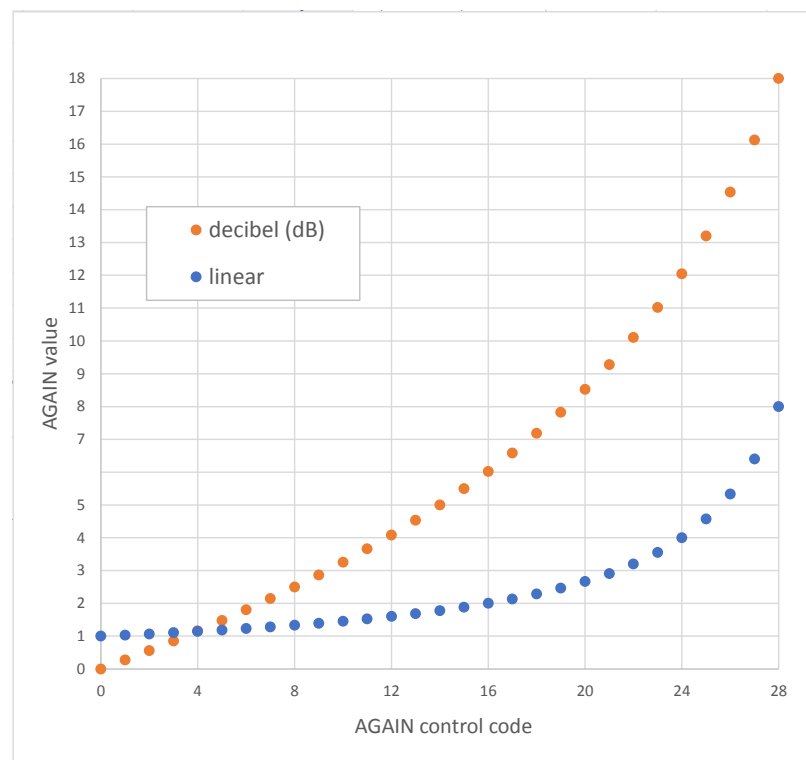
Four digital gains (one per color channel) can be applied, each of them ranging from 1.0 up to 8.0 minus one-step control with a step control of 1/256th so approximately 0.0039.

3.4.5 Autoexposure

The autoexposure (AE) feature computes and automatically applies the ideal exposure time and gain factors to get the optimum average luminance in the image. The autoexposure algorithm is performed directly in the sensors, to benefit from automatic exposure without the need to develop any dedicated algorithm or to allocate processor resources to the computation.

The sensors can also operate in manual mode where exposure parameters are provided by the host.

The host can configure autoexposure module parameters that control brightness target, convergence speed, and stability. The region of interest (ROI) used for autoexposure can be set independently from the image capture region.

A specific antiflickering mode can be selected to mitigate artifacts introduced by ambient light frequency and frame rate differences.

A dedicated I^2C status register provides the image average brightness information when the sensors are set to autoexposure or manual exposure mode. This information is also available in the status lines (ISL) embedded at the beginning of each frame. Refer to Section 3.4.8: Embedded status lines for ISL description.

3.4.6 Analog subsampling

The devices support x2 and x4 subsampling which reduces overall image size and keeps the same field of view (FoV). Subsampling is applied vertically and horizontally during the ADC readout, where every two or every four pixels are read. When subsampling is used, the frame rate can be increased by decreasing the frame length.

3.4.7 Digital binning

The digital binning process reduces the image resolution by a factor of 2 or 4 in each direction. Central and neighboring pixels are weighted to produce the digital binned image, avoiding special phase shift and artifacts which may occur on the output image. Digital binning and subsampling are mutually exclusive.

3.4.8 Embedded status lines

The output interface (OIF) embeds the intelligent status line generator, which allows metadata to be sent through the MIPI image data interface. The ISL follows the SMIA CSI-2, simplified, 2-byte, tagged data format for RAW8 data packing. There are two ISL lines transmitted at the beginning of each frame. Each data packet is 256 bytes long. The length of the ISL can be stretched to equal the active line packet size.

The MCU has access to a bank of status registers, refreshed at each frame, and providing detailed information on the current state of the sensors. Most of the content of this bank is also available in ISLs. The ISL contains all information related to the current transmitted frame such as:

- Clock settings
- Cropping and orientation parameters
- Analog and digital gains
- Integration time
- Frame counter index
- Thermal sensor values
- Dark calibration parameters

Transmission of ISL data packets can be disabled by configuring a static register during SW_STANDBY state before streaming. ISL data packets have their own programmable "data types" and "virtual channels".

3.4.9 Output interface

The output interface (OIF) embeds two data lanes of the MIPI D-PHY interface. It supports up to 1.5 Gbps of data per lane. The OIF outputs active pixel data in RAW10 or RAW8.
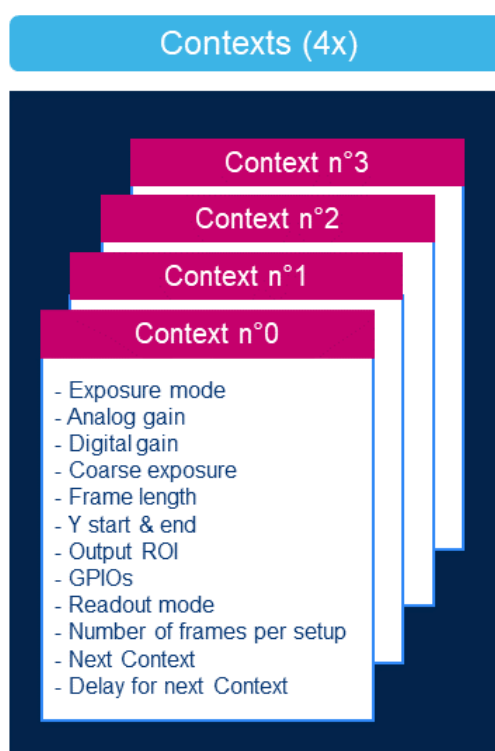
The OIF can output a combination of the following:

- Intelligent status lines
- Active pixel data

The OIF supports multiple virtual channels and different data types for active pixels and ISL data.

3.4.10 Context management

The sensors allow the configuration of up to four different rolling contexts (or frame setups). Parameters that can be specifically defined in a context are listed in the figure below.

Figure 5. Context parameters

Contexts (4x)

Context n°3
Context n°2
Context n°1
Context n°0

- Exposure mode
- Analog gain
- Digital gain
- Coarse exposure
- Frame length
- Y start & end
- Output ROI
- GPIOs
- Readout mode
- Number of frames per setup
- Next Context
- Delay for next Context

Contexts can be chained one to another in an ending or non-ending sequence.

Figure 6. Example of ending and non-ending multicontext sequence
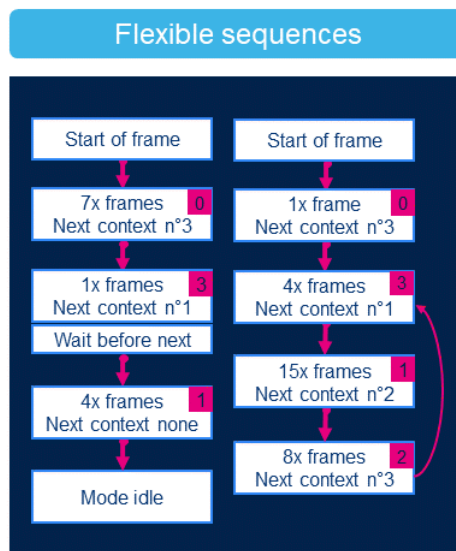
For the VD56G3CCA/RW, GPIO configurations are applied at the end of the current frame. If there is a context change including a different GPIO configuration, the new GPIO settings are applied at the second frame of this new context.
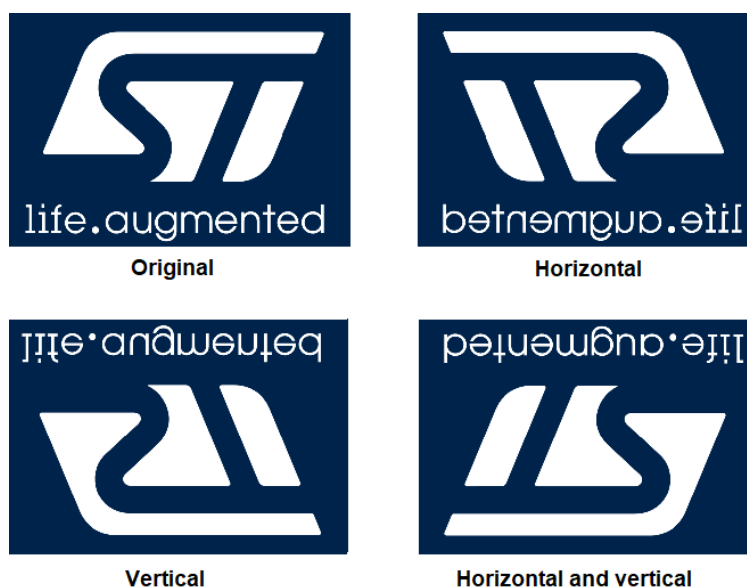
3.4.11 Cropping

The host can accurately choose which area of the whole pixel array it receives. This reduces traffic on the CSI interface and saves processing time.

3.4.12 Orientation

The sensor's image can be horizontally (mirror) and/or vertically flipped, as illustrated in the following figure.

Figure 7. Image orientation

3.5 Synchronization modes

The sensors have multiple synchronization modes:

1. Leader mode

    – Image streaming starts right after the execution of a streaming initialization command sent over the I^{2}C bus

    – After the initialization sequence, wait for a rising edge event on GPIO0 to start streaming images (only available for the VD56G3CCA/RW order code)

2. Follower mode

    – Using GPIO pulses

    – Using I²C triggering commands

## 3.6 General purpose input/outputs (GPIOs)

The sensors provide eight GPIOs:

• GPIO0 is used as a frame start synchronization signal or as a generic GPIO if not used for this function

• GPIO[1-7] are used as PWM outputs, pulse (strobe) outputs, VSYNC, or as a generic GPIO, as per the configuration

Figure 8. GPIO modes
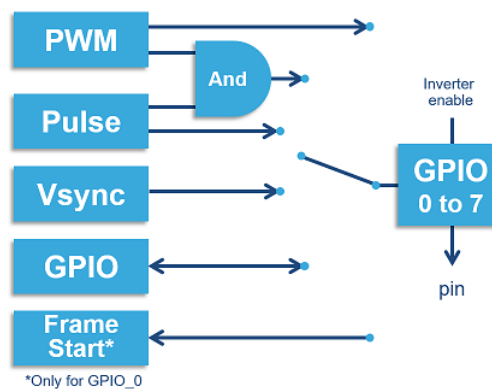
All GPIO settings are fully configurable for the four context setups. Each output signal can be mapped to one or several of the GPIOs. All GPIOs have configurable polarity.

Figure 9. PWM and pulse overview
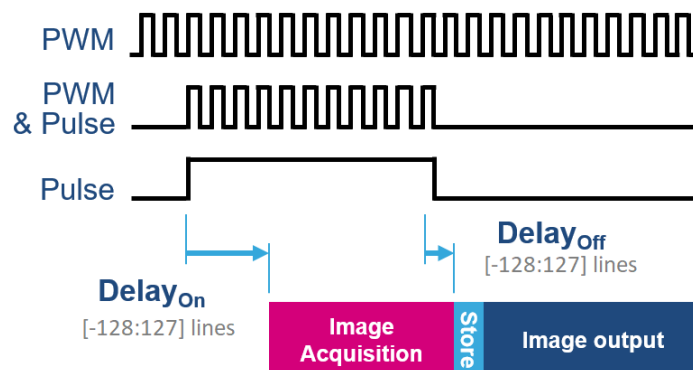
For the VD56G3CCA/RW, in SW_STANDBY state, the GPIOs can be set either as outputs (driven low or high) or as inputs.

3.7 Sensor firmware

The sensors present to the host a user interface (bank of registers), accessible via the I²C bus.

The host writes high-level parameters in the user interface and an MCU inside the sensors applies the proper sensor configuration based on UI settings provided by the host.

The firmware managing this MCU is located in a ROM but may have to be updated before streaming (code patching). This consists of a sequence of data transmission over the I²C bus.

The VD56G3CCA/RW does not require such a sequence. It requires a sequence of nearly 26 Kbytes to load. The patch sequence is provided by STMicroelectronics.

3.8 Use case examples

Table 3. Example of functional use cases

| Resolution	Maximum fps	Typical data rate
1124 x 1364	88	2 lanes, 800 Mbps per lane
1124 x 1364	88	1 lane, 1500 Mbps
720 x 1280	90	2 lanes, 800 Mbps per lane
640 x 480	210	1 lane at 1500 Mbps
320 x 240	360	1 lane at 1500 Mbps

4 Die specification

In the table below, the die dimensions are after sawing.

Table 4. Die dimensions

Description	North, (+y) µm	East, (+x) µm	South, (-y) µm	West, (-x) µm
Chip center	0.0	0.0	0.0	0.0
Optical center	—	-0.2	-17.80	—
First active pixel	1767.44	1471.84	-1803.04	-1472.24
First µlens	—	—	—	—
Inner edge of pad	2025.9	1665.9	-2025.9	-1665.9
Center of pad	2065.9	1705.9	-2065.9	-1705.9
Edge of chip	2184 ±10	1824 ±10	-2184 ±10	-1824 ±10
1/2 scribe width	50.0	50.0	50.0	50.0

Figure 10. Die mechanical dimensions (µm)
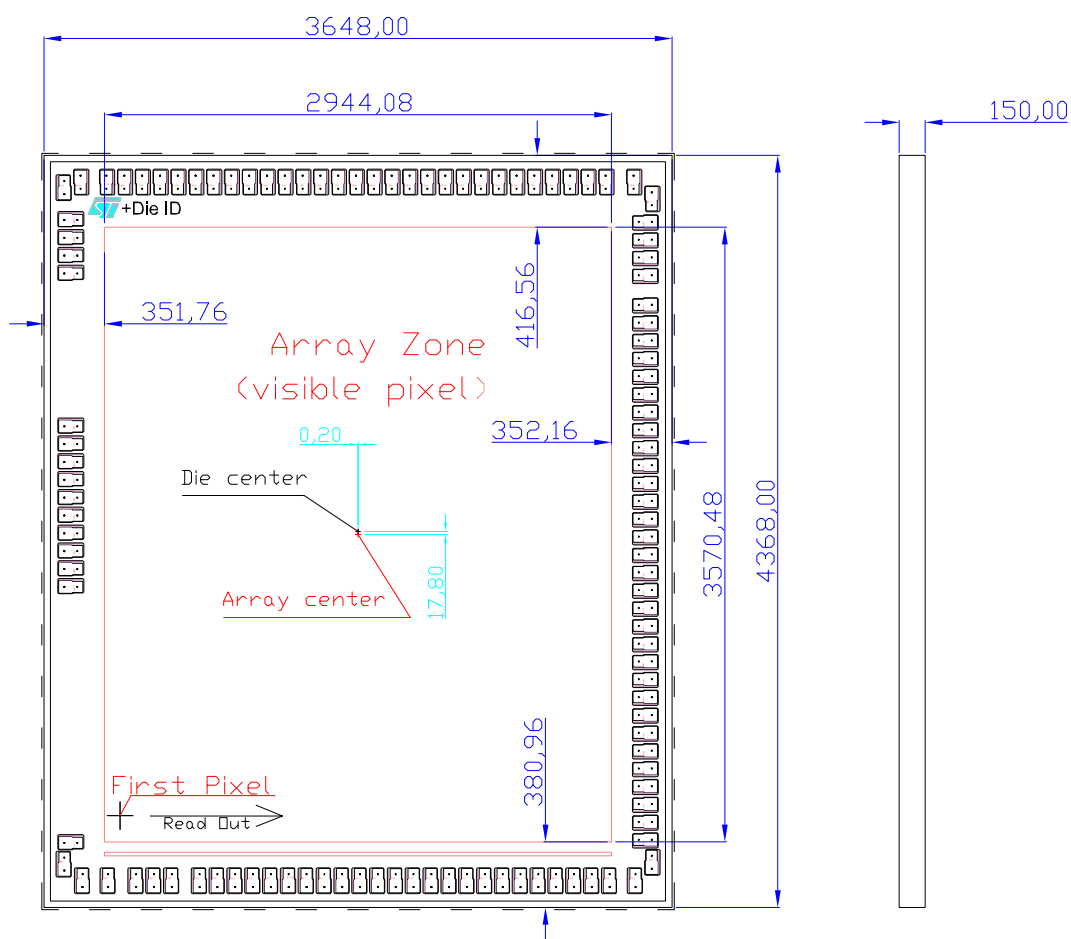
5 Package information

To meet environmental requirements, ST offers these devices in different grades of ECOPACK packages, depending on their level of environmental compliance. ECOPACK specifications, grade definitions, and product status are available at: www.st.com. ECOPACK is an ST trademark.

5.1 OBGA package information

The bond line thickness (substrate to silicon interface) is 20 μm.

The silicon die thickness is 200 μm.

The focusing plan is designed to be on the top surface of the silicon with an height tolerance of ±30 μm.

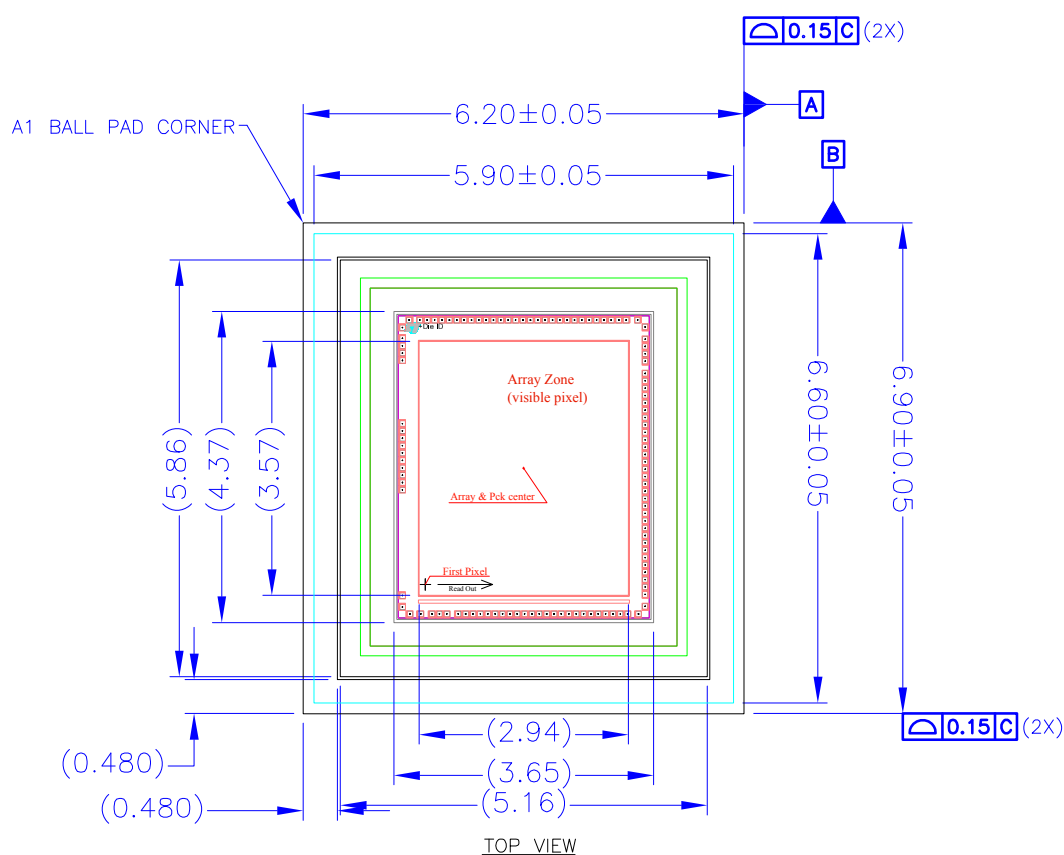Focusing plan tilt is maximum 25 μm.

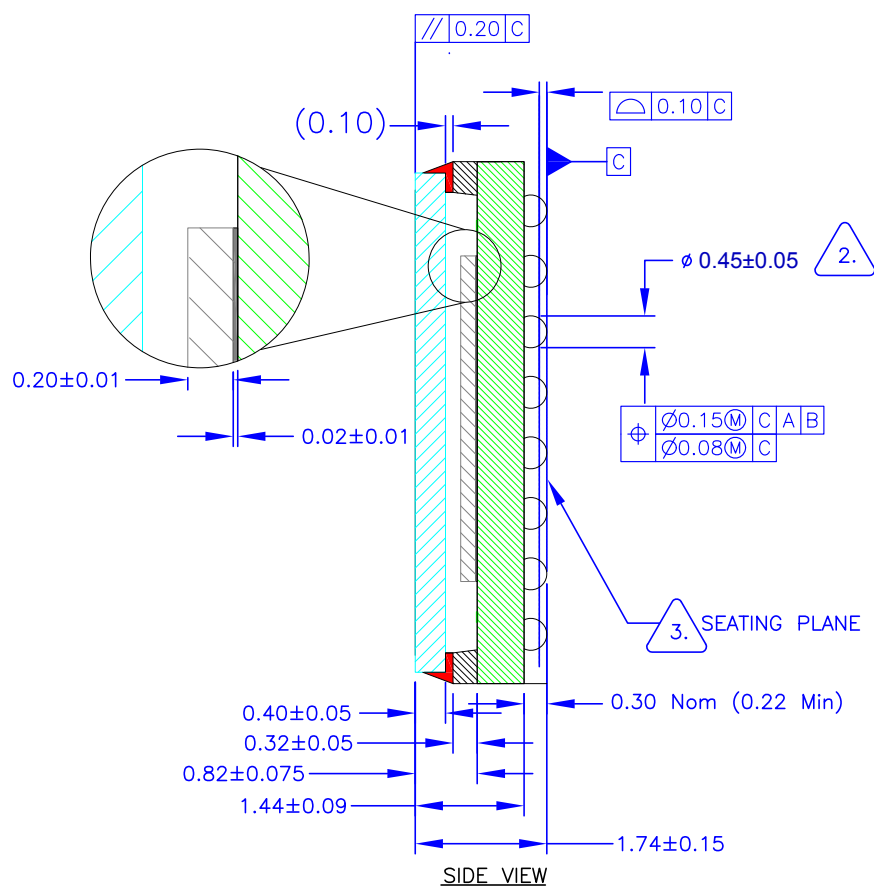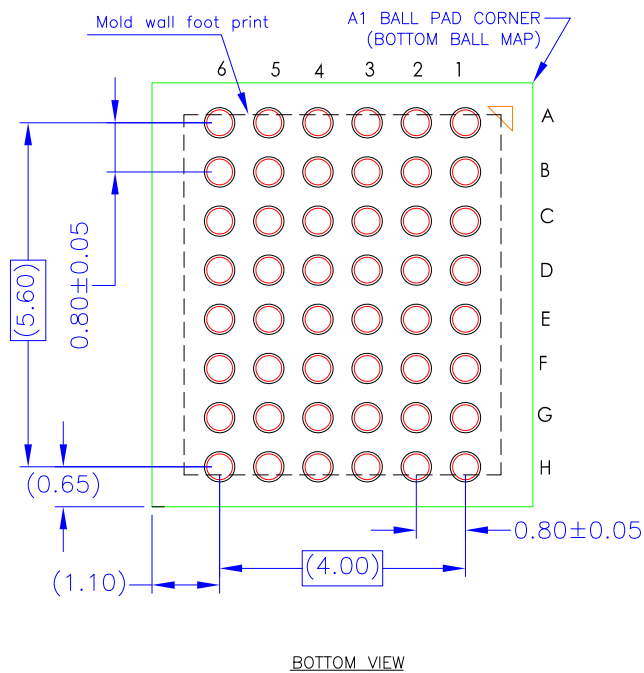**Figure 11. Top view**

Figure 12. Side view

SIDE VIEW

Figure 13. Bottom view

BOTTOM VIEW

5.2 Glass reflectance and transmittance

Table 5. Glass reflectance and transmittance

Items		Requirements			
Glass optical specification		Band nm	0° [1]	30° [1]	5° [1]
	Transmittance (T)	900-1000	Tminimum > 97.5%	Tminimum > 97%	
	Reflectivity (R)	900-1000	—		Raverage < 1.5%
					Rmaximum < 2%

1. *Incidence angle*

5.3 Soldering information

The OBGA packages are compliant with the RoHS and "green" standards and are qualified for soldering heat resistance according to JEDEC J-STD-020.

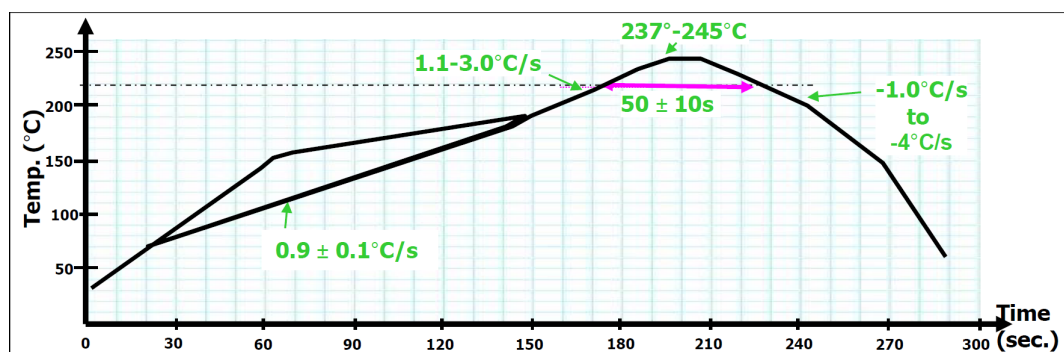**Figure 14. Soldering temperature vs time**

Table 6. Soldering details

Profil	Ramp to strike
Temperature gradient in preheat (T = 70-180°C)	0.9 ± 0.1°C/s
Temperature gradient (T = 200-225°C)	1.1 - 3.0°C/s
Peak temperature in reflow	237°C - 245°C
Time above 220°C	50 ± 10 s
Temperature gradient in cooling	-1 to -4°C/s (-6°C /s max.)
Temperature from 50°C to 220°C	160 to 220 s

6   Pin description and assignment

Table 7. Pin description

| Pin name	Type	Description	Reset state	Reference supply
Power supply				
VCORE	PWR	1.15 V power supply for the digital core		1.15 V
VDDIO		1.8 V power supply for I/Os		1.8 V
VANA		2.8 V analog power supply		2.8 V
DGND		Digital ground		VDDIO
AGND		Analog ground		VANA
Reference				
LDO2V4	REF	Internal reference (must be connected together)		VANA
VCPNEG_IN		Must be connected to VCPNEG_OUT		
VCPNEG_OUT		Must be connected to VCPNEG_IN		
VCPPOS_IN		Must be connected to VCPPOS_OUT		
VCPPOS_OUT		Must be connected to VCPPOS_IN		
VDDAMP		All VDDAMP (internal reference) must be connected together		VDDIO
CSI-2 interface				
DATA1P, DATA1N	MIPI DPHY	CSI-2 data lane 1, positive and negative	Low	VCORE
DATA2P, DATA2N		CSI-2 data lane 2, positive and negative		
CLKP, CLKN		CSI-2 clock, positive and negative		
Host interface				
XSHUTDOWN	I	Reset active low		VDDIO
SDA	I/O	I^{2}C data		
SCL	I	I^{2}C clock		
GPIO0	I/O	General-purpose I/O and strobe light control	Low	
GPIO1				
GPIO2				
GPIO3				
GPIO4				
GPIO5				
GPIO6				
GPIO7				
CLKIN	I	Input clock		
Other pins				
PORTEST	I	Must be connected to digital ground		VDDIO
NC		Not connected		
RCALIB		Not connected		

Table 8. Pin coordinates

The pin coordinates (0, 0) are the die center

Pin number	Bonding point X coordinate	Bonding point Y coordinate	Net name
1	-1611.62	2065.9	VCPPOS_OUT
2	-1461.56	2065.9	VANA
3	-1357.52	2065.9	AGND
4	-1253.97	2065.9	DGND
5	-1150.42	2065.9	VCORE
6	-1046.87	2065.9	AGND
7	-943.32	2065.9	DGND
8	-839.77	2065.9	VCORE
9	-736.22	2065.9	VANA
10	-632.67	2065.9	VANA
11	-529.12	2065.9	AGND
12	-425.57	2065.9	VCORE
13	-322.02	2065.9	NC
14	-218.47	2065.9	VANA
15	-114.92	2065.9	NC
16	-11.37	2065.9	AGND
17	92.18	2065.9	VANA
18	195.73	2065.9	DGND
19	299.28	2065.9	VCORE
20	402.83	2065.9	DGND
21	506.38	2065.9	VANA
22	609.93	2065.9	AGND
23	713.48	2065.9	VANA
24	817.03	2065.9	AGND
25	920.62	2065.9	DGND
26	1024.17	2065.9	DGND
27	1127.77	2065.9	SDA
28	1231.32	2065.9	SCL
29	1334.87	2065.9	VCORE
30	1438.42	2065.9	XSHUTDOWN
31	1600.34	2065.9	VDDIO
32	1705.9	1969.53	NC
33	1705.9	1798.29	GPIO0
34	1705.9	1694.72	PORTST
35	1705.9	1591.15	DGND
36	1705.9	1487.58	GPIO1
37	1705.9	1316.29	GPIO2
38	1705.9	1212.71	DGND
39	1705.9	1109.14	VCORE
40	1705.9	1005.58	DGND

Pin number	Bonding point X coordinate	Bonding point Y coordinate	Net name
41	1705.9	902	VCORE
42	1705.9	798.44	DGND
43	1705.9	694.87	LDO2V4
44	1705.9	591.29	VCORE
45	1705.9	487.73	DGND
46	1705.9	384.16	VDDIO
47	1705.9	280.58	GPIO3
48	1705.9	177.02	VCORE
49	1705.9	73.44	DGND
50	1705.9	-30.13	GPIO4
51	1705.9	-133.69	NC
52	1705.9	-237.26	VCORE
53	1705.9	-340.83	DGND
54	1705.9	-444.41	DGND
55	1705.9	-547.98	DGND
56	1705.9	-651.54	VCORE
57	1705.9	-755.12	AGND
58	1705.9	-858.69	GPIO5
59	1705.9	-962.25	GPIO6
60	1705.9	-1065.83	GPIO7
61	1705.9	-1169.39	VDDIO
62	1705.9	-1272.96	VANA
63	1705.9	-1376.54	LDO2V4
64	1705.9	-1480.11	DGND
65	1705.9	-1583.67	VCORE
66	1705.9	-1687.25	DGND
67	1705.9	-1790.82	CLKIN
68	1705.9	-1959.03	VDDIO
69	1611.63	-2065.9	DGND
70	1461.52	-2065.9	DGND
71	1357.95	-2065.9	VDDAMP
72	1254.38	-2065.9	VCORE
73	1150.81	-2065.9	DGND
74	1047.24	-2065.9	DGND
75	943.67	-2065.9	DATA2N
76	840.1	-2065.9	DATA2P
77	736.53	-2065.9	VDDAMP
78	632.96	-2065.9	CLKN
79	529.39	-2065.9	DGND
80	425.82	-2065.9	CLKP
81	322.25	-2065.9	VCORE

Pin number	Bonding point X coordinate	Bonding point Y coordinate	Net name
82	218.68	-2065.9	VDDAMP
83	115.11	-2065.9	DATA1N
84	11.54	-2065.9	DATA1P
85	-92.03	-2065.9	DGND
86	-195.6	-2065.9	LDO2V4
87	-299.17	-2065.9	VDDAMP
88	-402.74	-2065.9	RCALIB
89	-506.31	-2065.9	DGND
90	-609.88	-2065.9	VCORE
91	-713.45	-2065.9	AGND
92	-817.02	-2065.9	AGND
93	-920.59	-2065.9	NC
94	-1081.63	-2065.9	NC
95	-1185.2	-2065.9	DGND
96	-1288.77	-2065.9	AGND
97	-1451.06	-2065.9	VCORE
98	-1601.12	-2065.9	VANA
99	-1705.9	-1969.53	AGND
100	-1705.9	-1808.5	VCPNEG_IN
101	-1705.9	-321.68	VCPNEG_OUT
102	-1705.9	-218.11	AGND
103	-1705.9	-114.54	DGND
104	-1705.9	-10.97	VANA
105	-1705.9	92.6	VANA
106	-1705.9	196.17	NC
107	-1705.9	299.74	NC
108	-1705.9	403.31	NC
109	-1705.9	506.88	VCORE
110	-1705.9	610.45	AGND
111	-1705.9	1498.25	VCPPOS_IN
112	-1705.9	1601.82	VCORE
113	-1705.9	1705.38	VANA
114	-1705.9	1808.95	AGND
115	-1705.9	1959.04	VANA

Figure 15. Ball positions (see-through view)
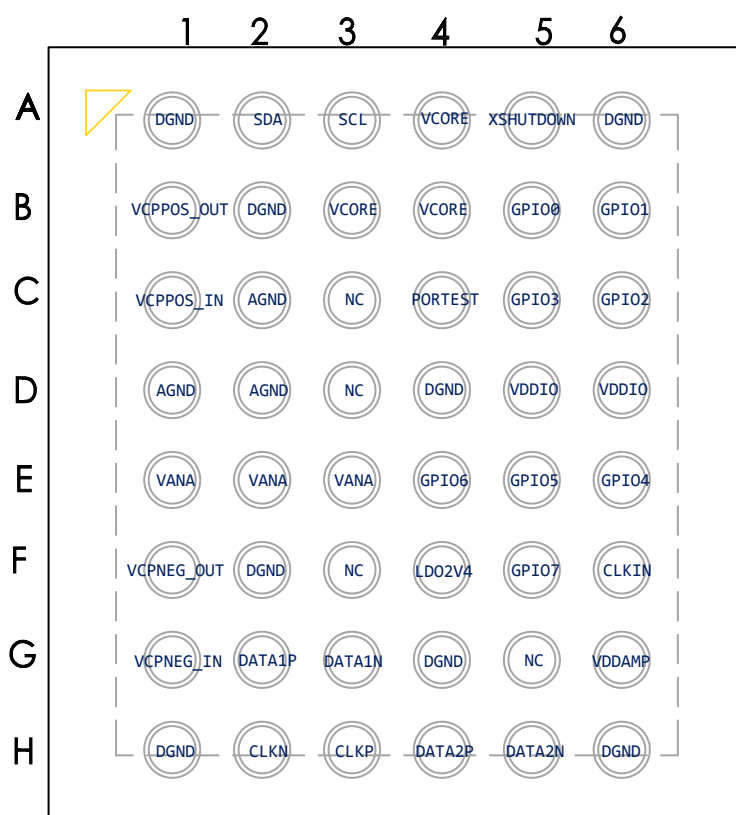
7 Application schematic

7.1 Additional components

Dedicated additional capacitors are required to complete the circuit. These are listed in Table 9. Capacitor needs below. The capacitors should be selected to maintain their capacitance value within the indicated tolerance over the full range of maximum voltages, operating temperatures, and aging.

Capacitor values are based on capacitor positions (embedded in the camera module or external to the camera module).

External capacitors are required to properly filter out supply noise. Optimal reference in terms of value and size is subject to application board architecture and topology. The external capacitor values provided in the table below may be increased to compensate real supply noise.

Table 9. Capacitor needs

Associated pin name	Capacitor position	Typical voltage	Minimum capacitance	Typical capacitance	Maximum capacitance	Operating frequencies	Capacitor ground	Purpose
CPPOS_IN, CPPOS_OUT	Embedded	3.55 V	330 nF	470 nF	560 nF	160 MHz	AGND	CP tank capacitor
CPNEG_IN, CPNEG_OUT	Embedded	-2.0 V	650 nF	0.88 µF	1.04 µF	160 MHz	AGND	CP tank capacitor
VDDIO	Embedded	1.8 V				1 MHz	DGND	Supply decoupling
	External		1 µF					
VCORE	Embedded	1.15 V		470 nF		800 MHz / 1 GHz - 1.5 GHz	DGND	Supply decoupling
	External			10 µF		160 MHz - 200 MHz	DGND	Supply decoupling
VANA	Embedded	2.8 V		100 nF		160 MHz	AGND	Supply decoupling
	External			10 µF				
LDO2V4	Embedded	2.4 V	100 nF		1 µF	DC	AGND	LDO capacitor
VDDAMP	Embedded	1.15 V	100 nF		1 µF	1.5 GHz	DGND	Supply decoupling

Figure 16. Application schematic for bare die
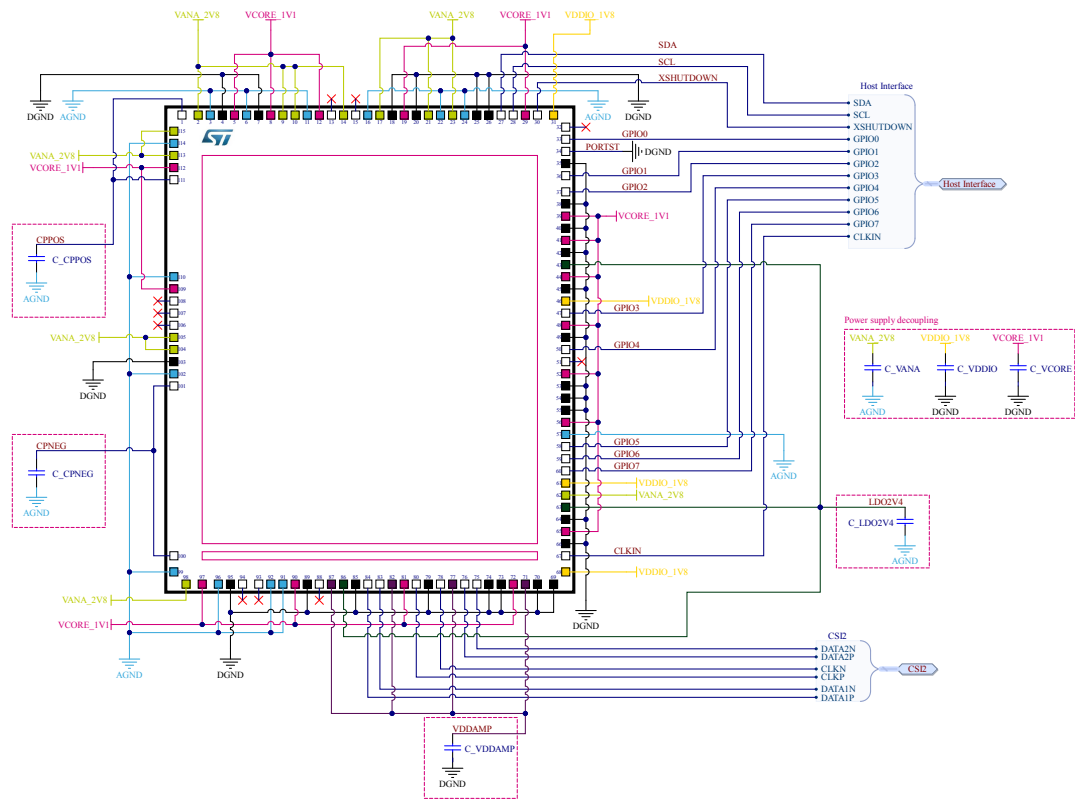
Figure 17. Application schematic for OBGA
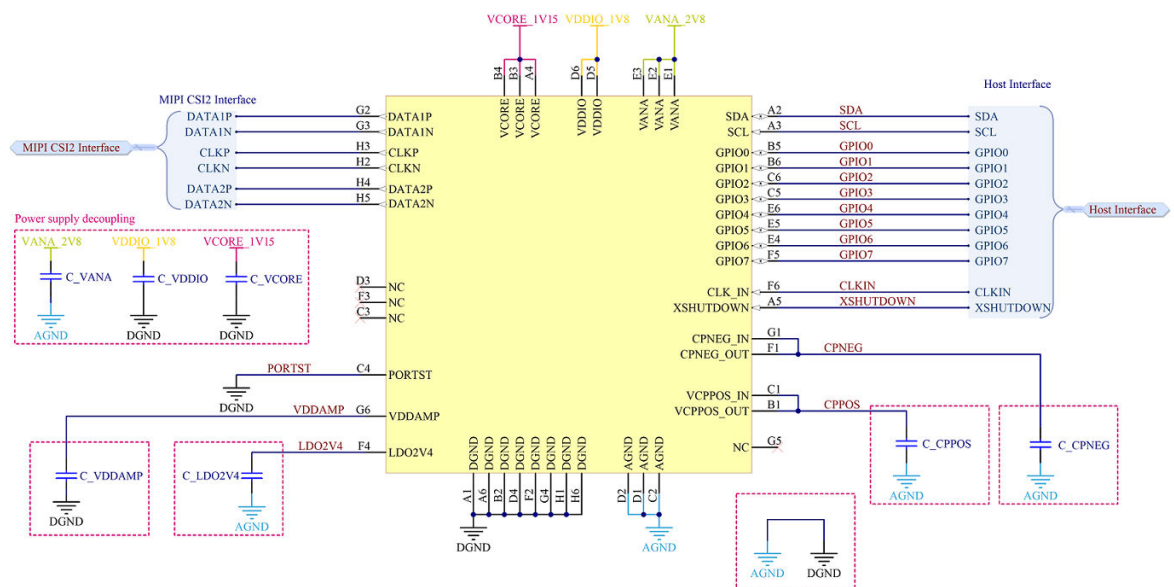
7.2 Layout guidelines

For good PCB design practice, observe the following image sensor layout:

- Use power and ground planes to supply power to the sensors.
- Join grounds i.e. join AGND and DGND into one single, solid GND plane underneath the sensors.
- Connect this GND plane to the sensor's pins with one via per GND pin.
- To minimize risk of emissions, shield all vias and tracks attached to supplies by their respective GND nets.
- Maximize copper fill on the power planes near the sensors and use vias to improve heat transfer from the sensors. Consider including additional heatsinks close to the sensors if they are to be used at high temperatures.
- Route the high-speed signal pairs of the MIPI CSI-2 interface with balanced and controlled impedance differential traces (50 Ω single-ended impedance, 100 Ω differential impedance). This is a requirement for high-speed signaling. Route each pair together and match them in length to target a maximum 10 ps skew.

VCPNEG_IN and VCPNEG_OUT must be connected together with a short track. The required decoupling capacitor shall be placed on this path and not on an isolated track.

VCPPOS_IN and VCPPOS_OUT must be connected together with a short track. The required decoupling capacitor shall be placed on this path and not on an isolated track.

7.3 Device power up sequence

To power on the devices:

- Provide all the external supplies (VCORE, VDDIO, VANA) according to the device characteristics described in Section 9: Electrical characteristics. As long as XSHUTDOWN is low, the devices are in HW_STANDBY state.
- You can switch on the external supplies and CLKIN in any order.
- Set XSHUTDOWN to high.

Figure 18. Power up sequence
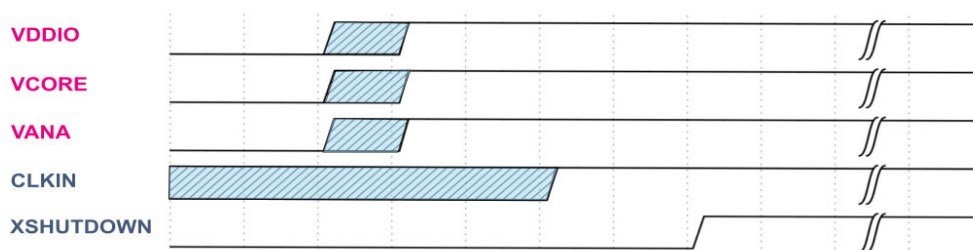
The devices have power-on-reset (POR) detection cells with hysteresis on VCORE and VDDIO power supplies. POR is released after a typical delay of 20 µs on the rising edge.

Bursts with a duration of less than 2 µs (typical) are ignored.

Table 10. POR typical threshold

Supply	POR typical threshold rising edge (V)	POR typical threshold falling edge (V)
VCORE	0.65	0.55
VDDIO	1.1	0.95

7.4 Device power down sequence

The power down sequence must be done as follows:

1. If the sensors are in STREAMING state, then set them to SW_STANDBY state and wait for the command to complete.
2. Set XSHUTDOWN to low.
3. External supplies can be switched off in any order, as well as CLKIN.

8 Pixel performance

The information listed in this section is for typical parts at ambient temperature (Tj = 40°C).

8.1 Quantum efficiency

Quantum efficiency (QE) is the percentage of incident photons converted into electrons, representing the sensitivity of the pixels.

Figure 19. VD56G3, VB56G3 quantum efficiency, gain 1
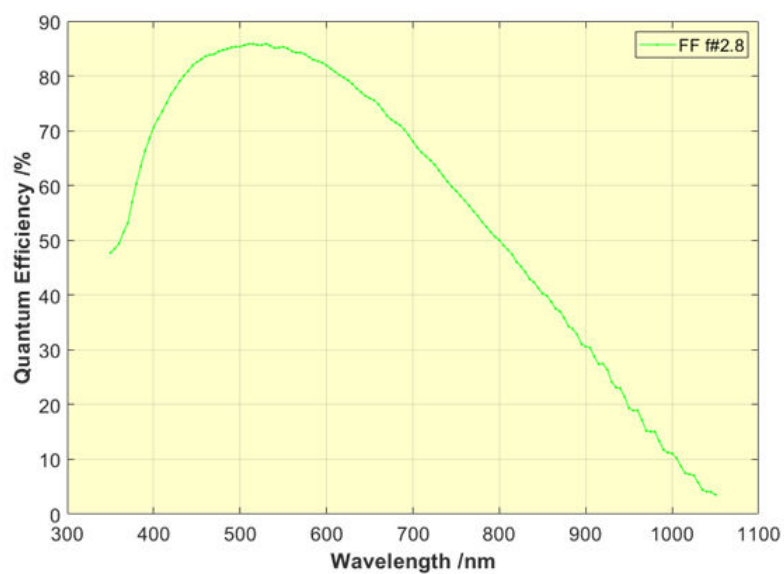
8.2 MTF

The modulation transfer function (MTF) measures the ability of the devices to differentiate spatial frequencies. The MTF value represents the contrast restitution for the corresponding spatial frequency. In other words, it describes the contrast attenuation. It is a sharpness indicator that quantifies the extent to which image sensors can capture and discriminate fine detailed contrast of objects within the field of view.

The figure below presents the on-axis MTF, measured in a 100x28 pixel ROI using the slanted-edge method. Note that in the following figure, Ny is the spatial Nyquist frequency.

Figure 20. On-axis vertical and horizontal pixel MTF @ 940 nm
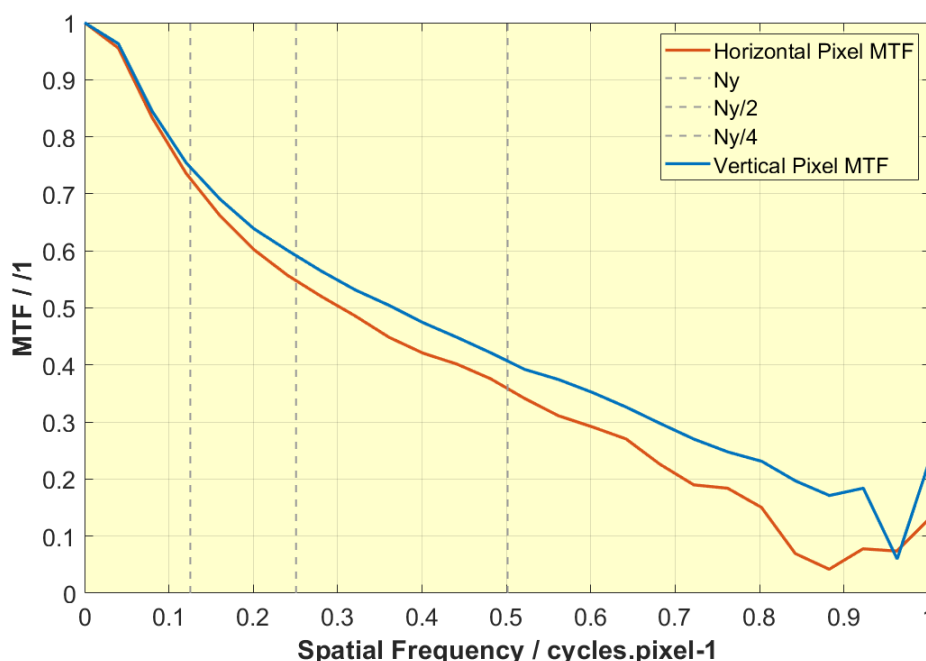
8.3 Microlenses and CRA matching

Each pixel of the matrix has its own microlens covering it.

The purpose of the microlens is to concentrate and optimize photon capture by passing through the module lens down to the photo diode to increase sensor light sensitivity and to maximize the amount of light received by each pixel.

The light beam has an incidence angle change when passing through the module lens, increasing from center to periphery. This is the chief ray angle (CRA).

To compensate for the change of CRA over the matrix, the microlens position over the pixels progressively shifts from matrix center to matrix borders.

The design of the sensor's microlens shift is optimized for matching a lens with CRA of 26° at corners and follows a linear shift shape.

It is recommended to match the CRA of the lens with the CRA of the image sensors to maximize image quality. Featuring advanced BSI pixel technology, the VD56G3, VB56G3 provide high relative illumination (RI) uniformity up to the image corners, which enables users to select lenses with different CRA with limited impact.

The following figure presents the CRA tolerance range in lens selection for maintaining a RI uniformity over 90% across the image.

Figure 21. Guideline for lens CRA matching
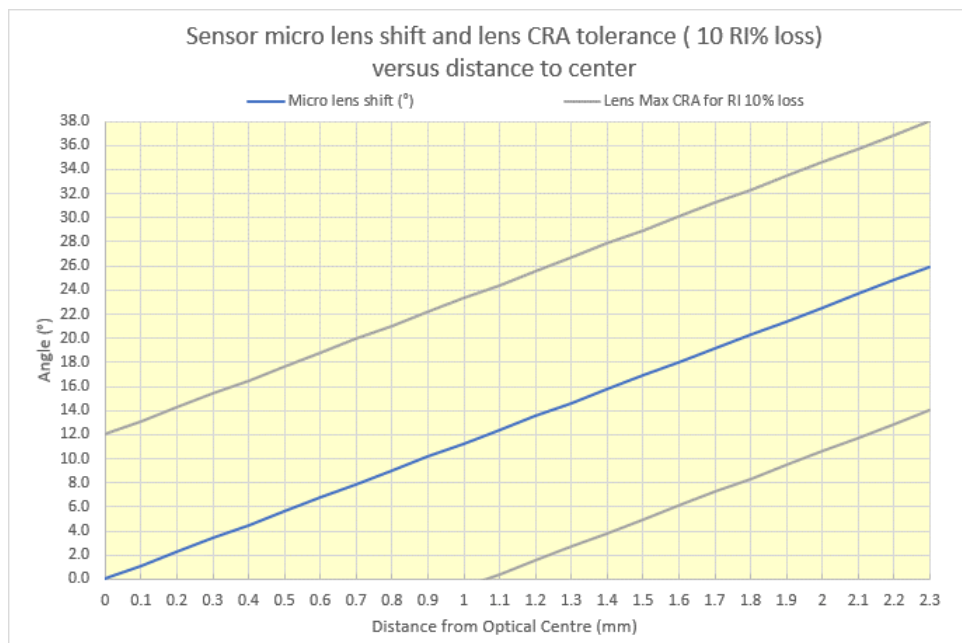
Figure 22. Co-centric pixel microlens CRA shift
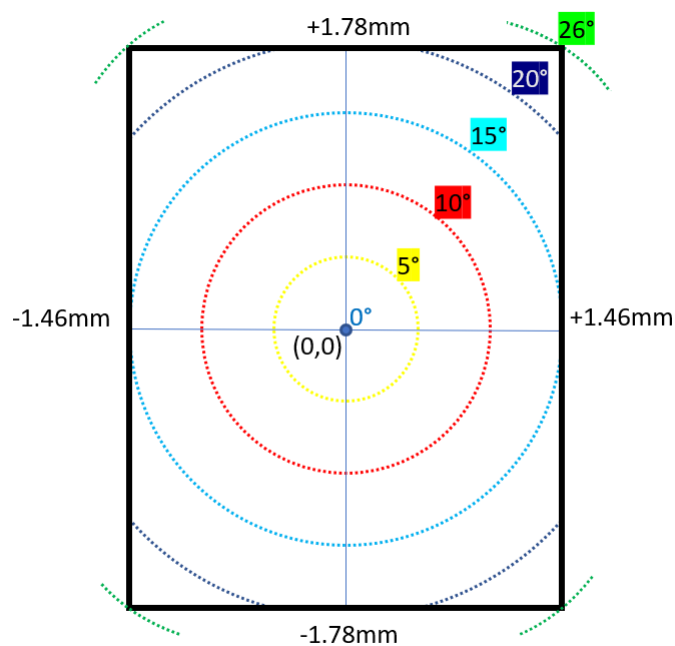
9 Electrical characteristics

The electrical characteristics have been measured under the following typical conditions:

•   Full resolution (1124 x 1364)
•   60 fps
•   Nominal power supply levels
•   External clock at 12 MHz
•   Junction temperature at 60°C
•   Nominal voltage

9.1 Absolute maximum ratings

Caution: *Stresses above those listed under "Absolute maximum ratings" may cause permanent damage to the devices. This is a stress rating only and functional operation of the devices at these or any other conditions above those indicated in the operational sections of the specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.*

Table 11. Absolute maximum ratings

Symbol	Parameter	Max	Unit
VDDIO	Digital I/O power supply	2.5	V
VANA	Analog power supply	3.5	V
VCORE	Digital core power supply	1.4	V
VIO	I/O referenced to VDDIO	2.5	V
VESD, electrostatic discharge model	Human body model (HBM)	±2	kV
	Charge device model (CDM)	±500	V

9.2 Operating conditions

Table 12. Operating conditions

Symbol	Parameter	Min.	Typ.	Max.	Unit
VDDIO	Digital I/O power supply	1.7	1.8	1.9	V
VANA	Analog power supply	2.65	2.8	2.95	
VCORE	Digital core power supply	1.08	1.15	1.26	
VIO	I/O referenced to VDDIO	-0.3	—	VDDIO + 0.3	
Temperature					
T JF	Junction temperature (functional operation)	-30	—	85	°C

9.3 Power consumption

Table 13. Typical power consumption

Values below are measured for the conditions listed in Section 9: Electrical characteristics, but they also include process variability.

State	VDDIO (nominal)			VCORE (nominal)			VANA (nominal)			Unit	Total power		Unit
	Min.	Typ.	Max.	Min.	Typ.	Max.	Min.	Typ.	Max.		Typ.	Max.	
Reset	0.0075	0.013	0.017	0.2	2.1	6.5	0.028	0.038	0.05	mA	2.5	—	mW
SW_STANDBY	0.0075	0.013	0.017	1	3.3	7.5	0.028	0.043	0.05		4	—	
Streaming image 60 fps	7.5	8.5	11.0	50	57	65	18	22.8	25		145	—	
Leader mode 30 fps	—	6.8	—	—	49.5	—	—	17.4	—		120	—	
Follower mode 0 fps	—	5.5	—	—	43	—	—	13.5	—		97	—	

Table 14. Maximum supply consumption

Values below are measured for the worst conditions of process, voltage, and temperature.

State	VDDIO (mA)	VCORE (mA)	VANA (mA)
SW_STANDBY	0.02	23	0.1
Streaming image 60 fps	11	86	25

9.3.1 Current profile

Figure 23. Start streaming and the first frame of typical current profile (mA) over time (ms)
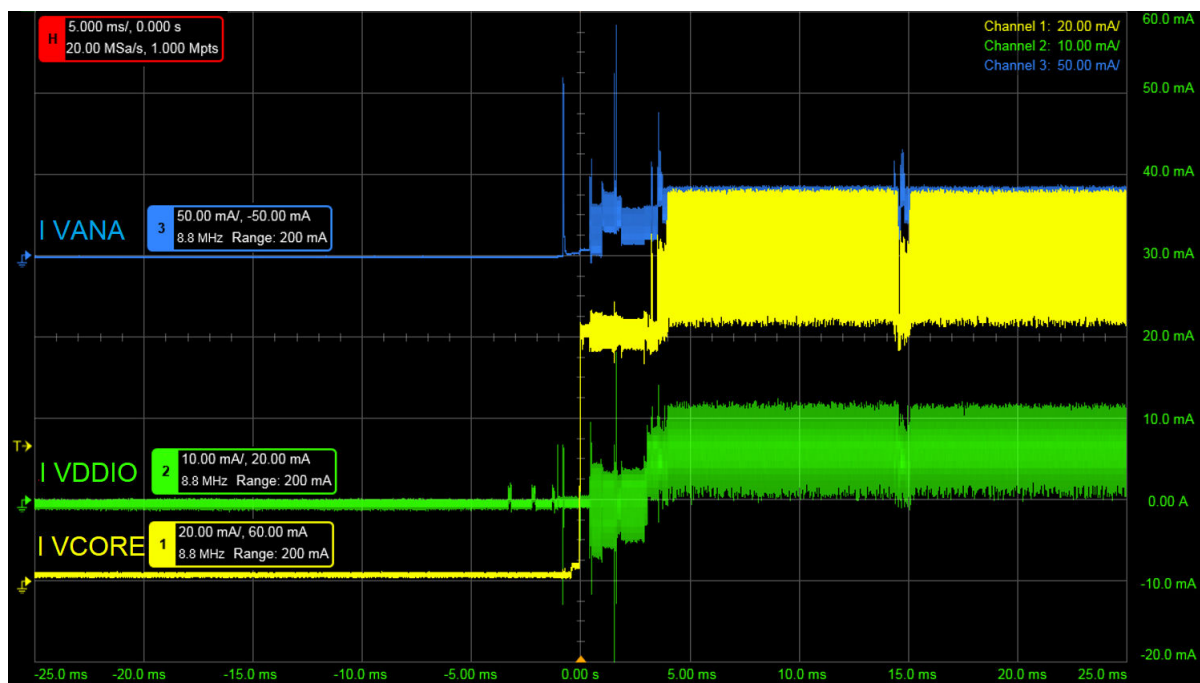
Note: *Figure 23. Start streaming and the first frame of typical current profile (mA) over time (ms) is captured at maximum temperature and voltage.*

Figure 24. Detail of VANA first transient pulse energy
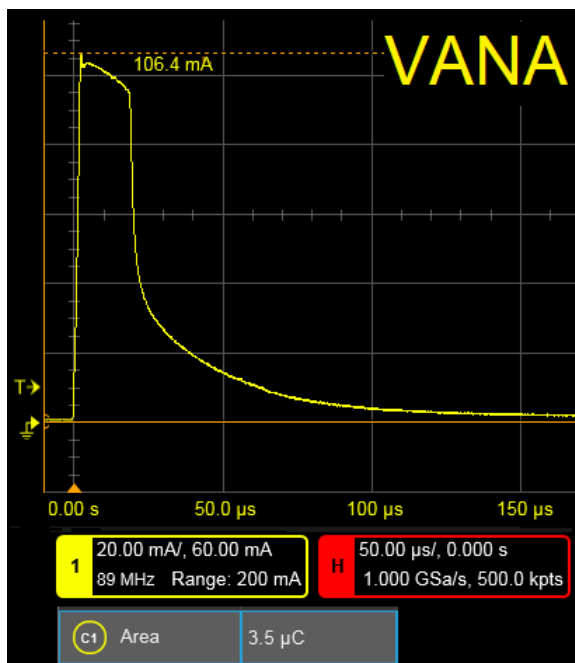
9.4   CLKIN input

Table 15. Typical CLKIN input

The CLKIN input is for all voltage and temperature conditions.

Symbol	Parameter	Min.	Max.	Unit
V_{CLKINL}	DC-coupled square wave low-level input	-0.3	0.3 x VDDIO	V
V_{CLKINH}	DC-coupled square wave high-level input	0.7 x VDDIO	VDDIO + 0.3	
f_{CLKIN}	Clock input frequency	6	27	MHz
CtoCjitter	Clock maximum cycle-to-cycle jitter	—	200	ps
Duty cycle	Clock duty cycle	40	60	%
I_{CLKIN}	Input leakage current	—	10	µA

9.5   Digital inputs

Table 16. Digital inputs over process variations at 60°C

Symbol	Parameter	Min.	Max.	Unit
V_{IL}	Low-level input voltage	-0.3	0.3 x VDDIO	V
V_{IH}	High-level input voltage	0.7 x VDDIO	VDDIO + 0.3	
I_{Leak}	Input leakage current [1]	—	10	µA

1.   For 0 ≤ VI ≤ VDDIO

9.6 Digital outputs

Table 17. Digital outputs

The digital outputs are over process variations at 60°C.

Symbol	Parameter	Conditions	Min.	Max.	Unit
V_{OL}	Low-level output voltage	IOL = -4 mA	—	0.4	V
V_{OH}	High-level output voltage	IOH = 4 mA	VDDIO - 0.4V	—	
I_{max}	Maximum current	—	—	4	mA

9.7 I²C interface - SDA, SCL

Table 18. I²C timing

The values below are for all process, voltage, and temperature conditions.

Parameter	Symbol	Fast mode		Fast mode plus		Unit
		Min.	Max.	Min.	Max.	
SCL clock frequency	t_{SCL}	0	400	0	1000	kHz
Hold time (repeated) START condition. After this period, the first clock pulse is generated	$t_{HD.STA}$	0.6	—	0.26	—	
LOW period of the SCL clock	t_{LOW}	1.3	—	0.5	—	
HIGH period of the SCL clock	t_{HIGH}	0.6	—	0.26	—	µs
Setup time for a repeated START condition	$t_{SU.STA}$	0.6	—	0.26	—	
Data hold time	$t_{HD.DAT}$	0	—	0	—	
Data set-up time	$t_{SU.DAT}$	100	—	50	—	
Rise time of both SDA and SCL	t_R	20	300	—	120	ns
Fall time of both SDA and SCL	t_F	20 x (VDD/5.5 V)	300	15 x (VDD/5.5 V)	120	
Set-up time for STOP condition	$t_{SU.STO}$	0.6	—	0.26	—	µs
Bus free time between a STOP and START condition	t_{BUF}	1.3	—	0.5	—	
Capacity load for each bus line	C_O	—	400	—	550	pF
Data valid time	$t_{VD.DAT}$	—	0.9	—	0.45	µs
Data valid acknowledge time	$t_{VD.ACK}$	—	0.9	—	0.45	
Noise margin at LOW level for each connected device (including hysteresis)	V_{nL}	0.054 x VDD	—	0.054 x VDD	—	V
Noise margin at HIGH level for each connected device (including hysteresis)	V_{nH}		—		—	

Figure 25. I²C timing
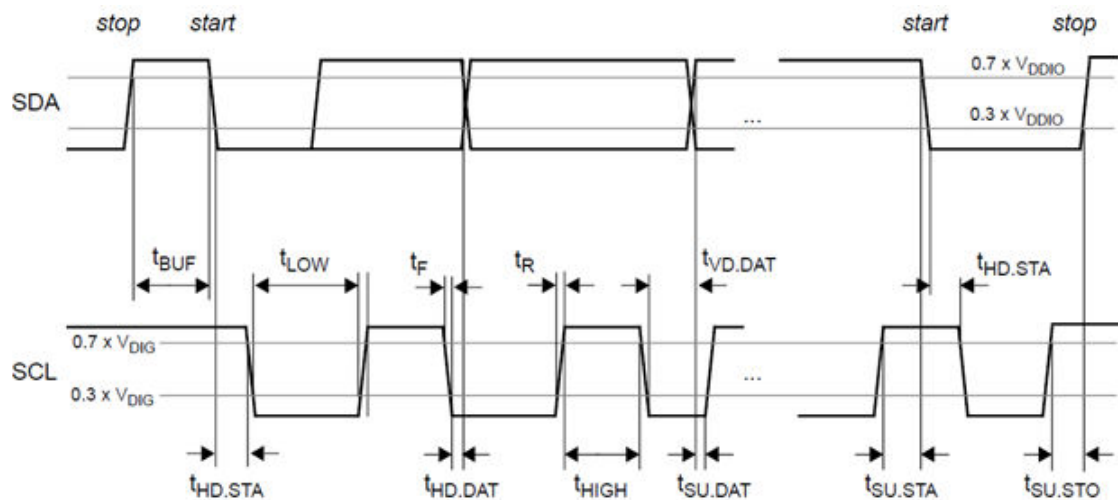
9.8 CSI-2 interface

9.8.1 DC specification

The DC specifications are evaluated by characterization for all process, voltage, and temperature conditions. They are not tested in production.

Table 19. CSI-2 interface - high-speed mode - DC specifications

Symbol	Parameter	Min	Typical	Max	Unit
V_{CMTX}	HS transmits static common-mode voltage	150	200	250	mV
V_{OD}	HS transmits differential voltage [1]	140	200	270	
V_{OHHS}	HS outputs high voltage [1]	—	—	360	
Z_{OS} [2]	Single-ended output impedance	40	50	62.5	Ω

1. Value when driving into load impedance anywhere in the ZID range (80-125 Ω)

2. Characterization data only

Table 20. CSI-2 interface - low-power mode - DC specifications

Symbol	Parameter	Min	Typical	Max	Unit
V_{OH}	Output high-level	1.1	1.2	1.3	V
V_{OL}	Output low-level	-50	—	50	mV
Z_{OLP}	Output impedance of LP transmitter	110	—	—	Ω

9.8.2 AC specification

Table 21. CSI-2 interface - high-speed mode - AC specifications

Symbol	Parameter	Min.	Typ.	Max.	Unit
—	Data rate	250	804	1500	Mbit/s
t_{clkp}	Average data period	—	1.25	—	ns
t_r and t_f	t_f 20% - 80% rise time and fall time	100	—	0.3UI	ps
t_{skew}	Data-to-clock skew	-0.15UI	—	0.15UI	ps

10   Packing information

10.1   Package delivery mode

Tested dice are delivered as sawn dice which are reconstructed into a wafer format on UV-tape, and delivered on a metallic ring (see figure below). The frames are packed in plastic containers, each including a maximum of 13 double-spaced reconstructed wafer rings. A mapping information file is also provided for localizing dice that may have been damaged during wafer reconstruction on sticking foil.

Figure 26. Reconstructed wafer information

FEATURE	DESCRIPTION
GRINDING THICKNESS	150um±7m
SINGULATED DIE SIZE	X=3648um±20um Y=4368um±20um
SCRIBE WIDTH	X=100um Y=100um
BOND PAD SIZE	141 × 75 um
BOND PAD OPENING	75x75um wire bond area
MINIMUM BOND PAD PITCH	103um
OPTICAL ARRAY (OPTICAL CENTER FROM DIE CENTER)	X=-0.2um Y=-17.8um
RECONSTRUCTED WAFER STREET WIDTH	500±50um
RW SIZE	≤200mm
RW OFFSET	(X1-X2)/2=0 ±5mm (Y1-Y2)/2=0 ±5mm
PLACEMENT ACCURACY X,Y,THETA	X,Y(±50um) Theta<1°
SHIPPING TAPE	UV TAPE (ADWILL D-175)
FILM FRAME	COMPACT DISCO STAINLESS SUS420
MAXIMUM TOTAL DIE COUNT	1460 EA
RW LAYOUT	X=47 Y=40

10.2 Product marking

Figure 27. Product marking example
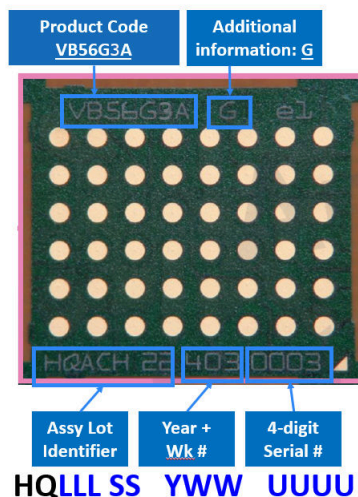
Product code: VB56G3

Additional information: G

Other marking information:

- HQ: Assembly plant code
- LLL: Assembly lot
- SS: Split characters
- Y: Assembly year (last digit of current year)
- WW: Assembly week (2 digits week number of this build)
- UUUU: Serial number (4 digit serial number of units in this build)

10.3 Tape and reel information

Figure 28. Reel description
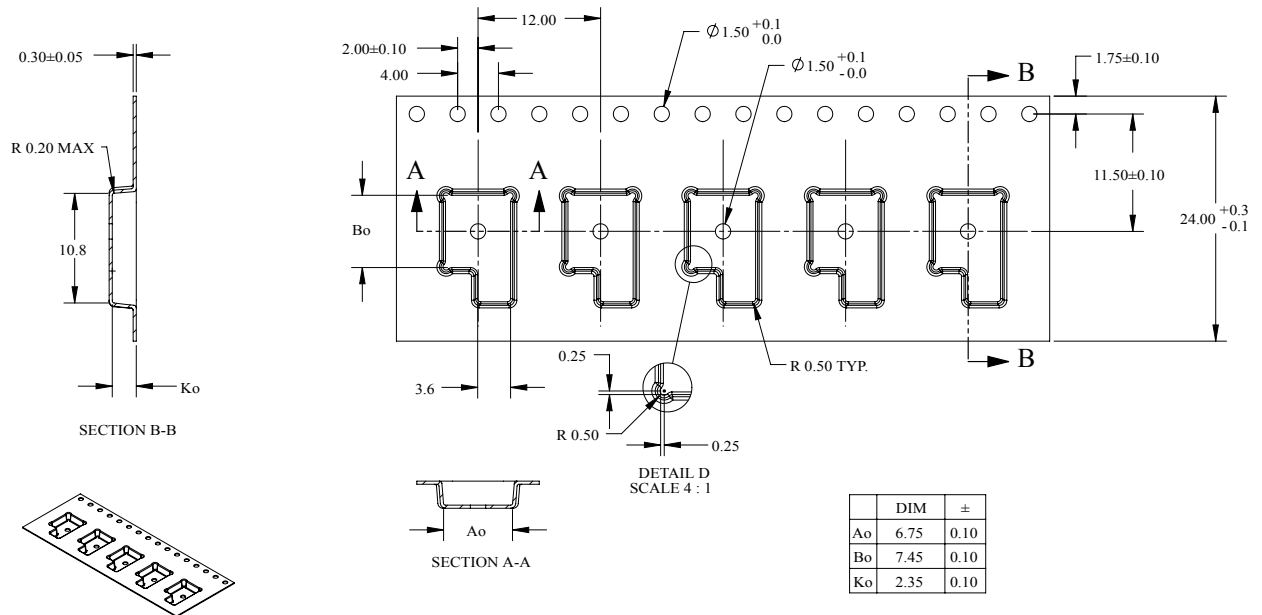
10.4 Storage information

Store all packing material in an appropriate indoor area. This is to prevent any dust and/or damage from the sun, external light, and physical shocks.

Keep the temperature between 15ºC and 35ºC.

Keep the relative humidity range between 10% and 70% maximum.

Store the reconstructed wafers under vacuum, in their original supplied sealed packing until they are used.

After the packing seal is broken, store the reconstructed wafers under nitrogen (N2) within dedicated closed shelves until they are processed.

Use the trace code to count the storage time. It is written on the package label.

The maximum storage time of the reconstructed wafer is:

• Six months from the trace code date. This is when the wafer is kept in the original sealed packing.

• One week from the trace code date. This is when the original packing seal is open.

The maximum storage time defines the maximum time that can be waited for reconstructed wafer processing. Processing may be for picking and placing, and module integration. If the maximm storage time is not respected, safe processing is not guaranteed.

Note: *For further information on reconstructed wafer specifications for visual inspection and packing, refer to the technical note TN1497.*

Revision history

<p align="center">**Table 22. Document revision history**</p>

Date	Version	Changes
18-Apr-2024	11	First public release
28-Oct-2025	12	Added the VB56G3 product. Updated the *document title*. Updated the *cover image*. Updated the *Device summary table*. Updated the *Features*. Updated the *Description*. Updated the *Applications*. Table 2. Technical specifications: added QE parameter details. Added Section 5.1: OBGA package information, Section 5.2: Glass reflectance and transmittance, and Section 5.3: Soldering information. Added Figure 15. Ball positions (see-through view). Updated Figure 16. Application schematic for bare die. Added Figure 17. Application schematic for OBGA. Updated layout of Section 10: Packing information and added Section 10.2: Product marking and Section 10.3: Tape and reel information.

Contents

IMPORTANT NOTICE – READ CAREFULLY